



ECPM 2012

Paul Scherrer Institut
Switzerland
May 9-12, 2012

XXXVIII European Cyclotron Progress Meeting
Paul Scherrer Institut
Villigen, Switzerland

Dear Colleagues

You are cordially invited to participate in the next European Cyclotron Progress Meeting (ECPM), May 9-12 in Villigen, Switzerland. The ECPM predominantly focuses on European activities and is held periodically between international cyclotron conferences. The meeting is devoted to cyclotrons and their applications. Status reports of existing facilities will be presented as well as new developments and evolving projects.

The meeting will be held at and hosted by the Paul Scherrer Institut (PSI). We will utilize the excellent infrastructure at the institute for the workshop and give participants the opportunity to visit accelerator facilities at PSI. More information on schedule, accommodation and travel options are given on the regularly updated website: <http://www.psi.ch/ecpm2012>.

call for papers and deadlines

Please submit your title, authors and abstract on our website and indicate whether you would like to present your contribution as a poster or a talk.

December 1, 2011:	registration and abstract submission open
March 9, 2012:	early registration closes; abstract submission closes
April 6, 2012:	late registration closes

educational session

As a result of the positive experience from the Groningen-ECPM we are planning to offer an introductory session on the physics and technology of cyclotrons. This session is primarily intended for students and will be planned for May 9th. It will be organized only if a sufficient number of participants register for this option. Interested students should register via email to ecpm2012@psi.ch before December 31 to allow us to estimate the participation in this session. We would also appreciate it if laboratory representatives who are aware of potentially interested students advertise this opportunity in their institutes.

On behalf of the ECPM-2012 organizational committee,
Mike Seidel.